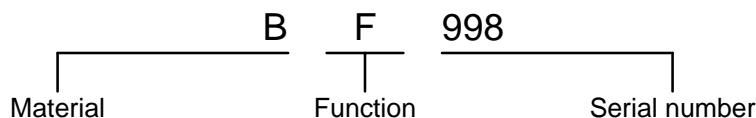


Conventions Used in Presenting Technical Data

Nomenclature for Semiconductor Devices According to Pro Electron

The part number of a semiconductor device consists of two letters followed by a serial number.

For example:



The **first letter** indicates the material used for the active part of the device.

- A GERMANIUM
(Materials with a bandgap 0.6–1.0 eV) ¹⁾
- B SILICON
(Materials with a bandgap 1.0–1.3 eV) ¹⁾
- C GALLIUM-ARSENIDE
(Materials with a bandgap > 1.3 eV) ¹⁾
- R COMPOUND MATERIALS
(For example Cadmium-Sulphide)

The **second letter** indicates the circuit function.

- A DIODE: detection, switching or mixer
- B DIODE: variable capacitance
- C TRANSISTOR: low power, audio frequency
- D TRANSISTOR: power, audio frequency
- E DIODE: tunnel
- F TRANSISTOR: low power, high frequency
- G DIODE: oscillator and miscellaneous
- H DIODE: magnetic sensitive
- K HALL EFFECT DEVICE:
in an open magnetic circuit
- L TRANSISTOR: power, high frequency
- M HALL EFFECT DEVICE:
in a closed magnetic circuit

- N PHOTO COUPLER
- P DIODE: radiation sensitive
- Q DIODE: radiation generating
- R THYRISTOR: low power
- S TRANSISTOR: low power, switching
- T THYRISTOR: power
- U TRANSISTOR: power, switching
- X DIODE: multiplier, e.g., varactor, step recovery
- Y DIODE: rectifying, booster
- Z DIODE: voltage reference or voltage regulator transient suppressor diode

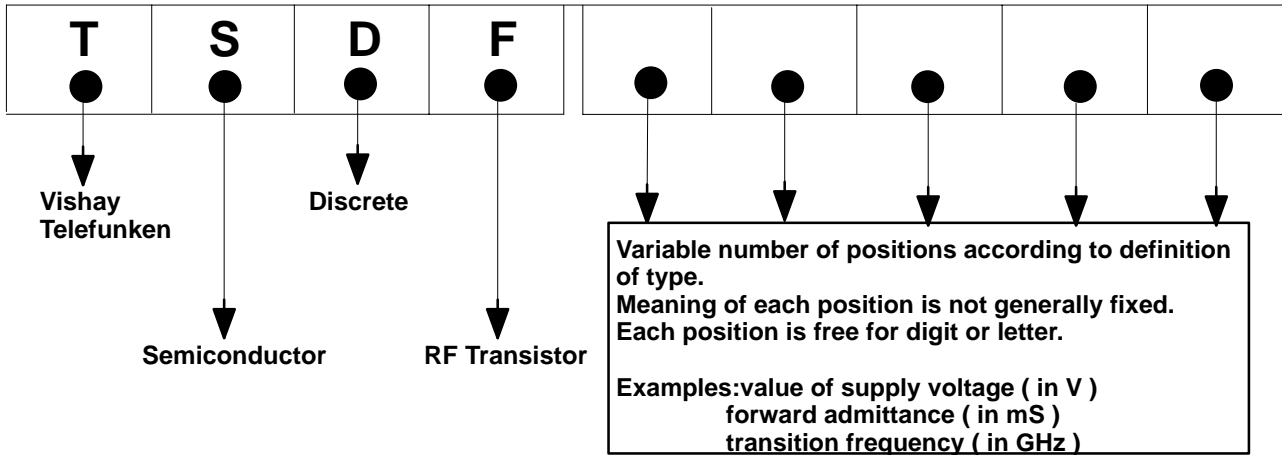
The **serial number** consists of:

- A four digit number from 100 to 9999 for devices primarily intended for consumer equipment.
- One letter (P, Q, R, etc.) and a three-digit number from 10 to 999 for devices primarily intended for professional equipment.

A version letter can be used to indicate a deviation of a single characteristic, either electrical or mechanical. This letter does not have a fixed meaning. The only exception is the use of the letter R, indicating reversed pinning or bending and W indicating SOT323 or SOT343 package.

¹⁾ The materials mentioned are examples

Most recent VISHAY Telefunken specific nomenclature for RF-Transistors



Arrangement of Symbols

Letter symbols for current, voltage and power (according to DIN 41 785, sheet 1)

To represent current, voltage and power, a system of basic letter symbols are used. Capital letters are used for the representation of peak, mean, dc or root-mean-square values. Lower case letters are used for the representation of instantaneous values which vary with time.

Capital letters are used as subscripts to represent continuous or total values, while lower case letters are used to represent varying values.

The following table summarizes the rules given above.

Basic letter	
Upper-case	Upper-case
Instantaneous values which vary with time	Maximum (peak) average (mean) continuous (dc) or root-mean-square (RMS) values

Subscript(s)	
Upper-case	Upper-case
Varying component alone, i.e., instantaneous, root-mean-square, maximum or average values	Continuous (without signal) or total (instantaneous, average or maximum) values

Letter symbols for impedance, admittances, two-port parameters etc.

For impedance, admittance, two-port parameters, etc., capital letters are used for the representation of external circuits of which the device is only a part. Lower case letters are used for the representation of electrical parameters inherent in the device.

The rules are not valid for inductance and capacitance. Both these quantities are denoted with capital letters.

Capital letters are used as subscripts for the designation of static (dc) values, while lower case letters are used for the designation of small-signal values.

If more than one subscript is used (h_{FE} , h_{fe}), the letter symbols are either all capital or all lower case.

If the subscript has numeric (single, double, etc.) as well as letter symbol(s) (such as h_{21E} or h_{21e}), the differentiation between static and small-signal value is made only by a subscript letter symbol.

Other quantities (values) which deviate from the above rules are given in the list of letter symbols.

The following table summarizes the rules given above.

Basic letter	
Upper-case	Upper-case
Electrical parameters inherent in the semiconductor devices except inductances and capacitances	Electrical parameters of external circuits and of circuits in which the semiconductor device forms only a part; all inductances and capacitances

Subscript(s)	
Upper-case	Upper-case
Small-signal values	Static (dc) values

Examples:

G_P	Power gain
h_{FE}	DC forward current transfer ratio in common emitter configuration
Z_S	Source impedance
f_T	Transition frequency

List of Symbols for RF Transistors

AQL	Acceptable Quality Level	E_L	Inductive energy
B,b	Base, base terminal	F, NF	Noise figure
C	Capacitance, general	f_{3dB}	3dB bandwidth
C,c	Collector, collector terminal	f_{IM}	Intermodulation frequency
C_{ce}	Capacitance between collector and emitter, without parasitic capacitances	f_{max}	Maximum frequency of oscillation
C_i	Short-circuit input capacitance	F_{opt}, NF_{opt}	Minimum noise figure
C_{ib}	Short-circuit input capacitance in common-base configuration	f_T	Transition frequency, gain bandwidth product
C_{ie}	Short-circuit input capacitance in common-emitter configuration	$F_{50\Omega}, NF_{50\Omega}$	Noise figure in 50Ω system
C_{issg1}	Gate 1-input capacitance in common-source configuration	G,g	Gate
C_{issg2}	Gate 2-input capacitance in common-source configuration	ΔG_p	Gain control range
C_o	Short-circuit output capacitance	g_i	Short-circuit input conductance
C_{ob}	Short-circuit output capacitance in common-base configuration	g_{ib}	Input conductance in common-base configuration, short circuit at output $g_{ib} = \text{Re}(y_{ib})$
C_{oe}	Short-circuit output capacitance in common-emitter configuration	g_{ie}	Input conductance in common-emitter configuration, short circuit at output $g_{ie} = \text{Re}(y_{ie})$
C_{oss}	Output capacitance in common-source configuration	G_L	Load conductance
C_{rss}	Feedback capacitance in common-emitter configuration	g_o	Short-circuit output conductance
C_r	Short-circuit reverse transfer capacitance	g_{ob}	Output conductance in common-base configuration, short circuit at input $g_{ob} = \text{Re}(y_{ob})$
C_{rb}	Feedback capacitance in common-base configuration	g_{oe}	Output conductance in common-base configuration, short circuit at input $g_{oe} = \text{Re}(y_{oe})$
C_{re}	Feedback capacitance in common-emitter configuration	g_r	Short-circuit reverse conductance
C_{cb}	Capacitance between collector and base without parasitic capacitances	G_{pb}	Power gain in common-base configuration
C_{CBO}	Capacitance between collector and base with open emitter	G_{pe}	Power gain in common-emitter configuration
C_{eb}	Capacitance between emitter and base without parasitic capacitances	G_{ps}	Power gain in common-source configuration
C_{EBO}	Capacitance between emitter and base with an open collector	G_S	Generator conductance
D	Drain	h_{FE}	DC forward current transfer ratio in common emitter configuration
d_{iM}	Signal-to-intermodulation ratio	h_{fe}	Short circuit forward current transfer ratio in common emitter configuration
E,e	Emitter	I_B	DC base current
E_{CB}	Collector base breakdown energy	I_{bias}	Biassing current, device current
		I_{BM}	Peak base current
		I_C	DC collector current
		I_{CBO}	Collector cut-off current with open emitter
		I_{CEO}	Collector cut-off current with open base
		I_{CER}	Collector cut-off current with a resistor R_{BE} connected between base and emitter

I_{CES}	Collector cut-off current, short between base and emitter	S_{12}	Reverse transmission coefficient in 50 Ω -system
I_{CEV}	Collector cut-off current with reverse base-emitter voltage	S_{21}	Forward transmission coefficient in 50 Ω -system
I_{CEX}	Collector cut-off current with forward base-emitter voltage	S_{22}	Output reflection coefficient in 50 Ω -system
I_{CM}	DC collector peak current	t	Time
I_D	Drain current	t_d	Delay time
I_{DSO}, I_{DSP}	Self-biased operating current	t_f	Fall time
I_{DSS}	Drain-source saturation current	t_{fr}	Forward recovery time
I_E	Emitter current	$\frac{t_p}{T}$	Duty cycle
I_{EBO}	Emitter cut-off current with open collector	t_{off}	Turn-off time
I_F	Forward current	t_{on}	Turn-on time
I_{G1SS}	Gate1-source leakage current	t_p	Pulse duration (time)
I_{G2SS}	Gate2-source leakage current	t_r	Rise time
IM_3	Intermodulation distortion third order	t_{rr}	Reverse recovery time
IP_3	Third order intercept point	t_s	Storage time
I_{RM}	Reverse recovery current	T	Temperature, measured in centigrade
K	Kelvin	T	Absolute temperature in Kelvin
L_s	Series inductance	T	Period duration
m	Degree of modulation	T_{amb}	Ambient temperature (range)
M_A	Tightening torque	T_{case}	Case temperature
$P_{(-1dB)}$	Output power at 1dB gain compression	T_{ch}	Channel temperature
P_{in}	Input power	T_j	Junction temperature
P_{out}	Output power	TK	Temperature coefficient
P_{tot}	Total power dissipation	T_{sd}	Soldering temperature
r_{bb}	Basic intrinsic resistance	T_{stg}	Storage temperature (range)
R_{BE}	Resistance connected between base and emitter	V_{BB}	Base supply voltage
r_F	DC forward resistance	V_{BE}	Base-emitter voltage
r_f	Differential forward resistance	V_{BEsat}	Base-saturation voltage
R_{G1}	External resistor to gate1	V_{CB}	Collector-base voltage
R_{thChA}	Thermal resistance, channel ambient	V_{CBO}	Collector-base voltage, open emitter
R_{thJA}	Thermal resistance, junction and ambient	$V_{(BR)CBO}$	Breakdown voltage, collector-base, open emitter
R_{thJC}	Thermal resistance, junction and case	V_{CC}	Collector supply voltage
s	Standing wave ratio (SWR)	V_{CE}	Collector-emitter voltage
S, s	Source	V_{CEO}	Collector-emitter voltage, open base
$ S_{21} ^2$	Transducer gain, power gain in 50 Ω -system	$V_{(BR)CEO}$	Collector-emitter breakdown voltage, open base
S_{11}	Input reflection coefficient in 50 Ω -system	V_{CER}	Collector-emitter voltage with a resistor R_{BE} connected between base and emitter
		V_{CES}	Collector-emitter voltage, short between base and emitter

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V_{CEsat} Collector–emitter saturation voltage	$ y_{re} $ Short–circuit reverse transfer admittance in common–emitter configuration (small signal value)
$V_{CEsatdyn}$ Dynamic saturation voltage	y_f Short –circuit forward transfer admittance
V_{CEV} Collector–emitter voltage with reverse base–emitter voltage	$ y_{fb} $ Short–circuit forward transfer admittance in common –base configuration (small signal value)
V_{CEW} Collector–emitter working voltage	$ y_{fs} $ Short–circuit forward admittance in a source configuration at a given operating point and frequency
V_d Device voltage	$ y_{21s} $ Short–circuit forward admittance in a source configuration at a given operating point and frequency
V_{DD} Drain supply voltage	y_o Short–circuit output admittance
V_{DS} Drain–source voltage	y_{ob} Short–circuit output admittance in common–base configuration (small–signal value)
$V_{(BR)DS}$ Drain–source breakdown voltage	y_{oe} Short–circuit output admittance in common–emitter configuration (small–signal value)
V_{EBO} Emitter–base voltage with open collector	$ y_r $ Moduls of the short–circuit reverse transfer admittance
$V_{(BR)EBO}$ Emitter–base, breakdown voltage, open collector	φ_r Phase of the short–circuit reverse transfer admittance
$V_{(BR)ECO}$ Emitter–collector, breakdown voltage, open base	$ y_f $ Moduls of the short–circuit forward transfer admittance
$\pm V_{(BR)G1SS}$ Gate 1–source breakdown voltage	φ_f Phase of the short–circuit forward transfer admittance
$\pm V_{(BR)G2SS}$ Gate 2–source breakdown voltage	φ Phase angle
V_F Forward voltage	φ_{fb} Phase of the short–circuit forward transfer admittance
V_{FP} Turn on transient peak voltage	φ_{fe} Phase of the short–circuit forward transfer admittance y_{fe}
$V_{G1S(OFF)}$ Gate 1–source cut–off voltage	φ_{rb} Phase of the short–circuit reverse transfer admittance y_{rb}
$V_{G2S(OFF)}$ Gate 2–source cut–off voltage	φ_{re} Phase of the short–circuit reverse transfer admittance y_{re}
V_{GG} Gate supply voltage	Z_0 System impedance
V_{SWR} Voltage standing wave ratio	Z_L Load impedance
y_{ib} Short –circuit input admittance in common–base configuration (small–signal value)	Z_S Source impedance
y_{ie} Short –circuit input admittance in common–emitter configuration (small–signal value)	
y_r Short –circuit reverse transfer admittance	

List of Symbols for Diodes

A	Anode	Q_{rr}	Reverse recovery charge
a	Distance (in mm)	R_F	Forward resistance
b_{pn}	Normalized power factor	r_f	Differential forward resistance
C	Capacitance, general	R_L	Load resistor
C_{case}	Case capacitance	r_P	Parallel resistance, damping resistance
C_D	Diode capacitance	R_R	Reverse resistance
C_j	Junction capacitance	r_r	Differential reverse resistance
C_L	Load capacitance	r_s	Series resistance
C_P	Parallel capacitance	R_{thJA}	Thermal resistance between junction and ambient
F	Noise figure	R_{thJC}	Thermal resistance between junction and case
f	Frequency	r_z	Differential Z-resistance in breakdown region (range) $r_z = r_{zj} + r_{zth}$
f_g	Cut-off-frequency	r_{zj}	Z-resistance at constant junction temperature, inherent Z-resistance
g	Conductance	r_{zth}	Thermal part of the Z-resistance
I_F	Forward current	T	Temperature, measured in centigrade
I_F	Forward current, instantaneous total value	T	Absolute temperature, Kelvin temperature
I_{FAV}	Average forward current, rectified current	T	Period duration
I_{FRM}	Repetitive peak forward current	T_{amb}	Ambient temperature (range)
I_{FSM}	Surge forward current, non-repetitive	t_{av}	Integration time
I_{FWM}	Crest working forward current	T_{case}	Case temperature
I_R	Reverse current	t_{fr}	Forward recovery time
i_R	Reverse current, instantaneous total value	T_j	Junction temperature
I_{RAV}	Average reverse current	TK	Temperature coefficient
I_{RRM}	Repetitive peak reverse current	T_L	Connecting lead temperature in the holder (soldering point) at the distance/(mm) from case
I_{RSM}	Non-repetitive peak reverse current	t_P	Pulse duration (time)
I_{RWM}	Crest working reverse current	$\frac{t_p}{T}$	Duty cycle
I_S	Supply current	t_r	Rise time
I_Z	Z-operating current	t_{rr}	Reverse recovery time
I_{ZM}	Z-maximum current	t_s	Storage time
l	Length (in mm), (case-holder/soldering point)	T_{sd}	Soldering temperature
LOCEP (local epitaxy)		T_{stg}	Storage temperature (range)
A registered trade mark of TEMIC for a process of epitaxial deposition on silicon. Applications occur in planer Z-diodes. It has an advantage compared to the normal process, with improved reverse current.		$V_{(BR)}$	Breakdown voltage
P	Power	V_F	Forward voltage
P_{tot}	Total power dissipation	V_F	Forward voltage, instantaneous total value
P_V	Power dissipation, general		
P_{vp}	Pulse-power dissipation		
Q	Quality		



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V_{FAV}	Average forward voltage	V_{RRM}	Repetitive peak reverse voltage
V_o	Rectified voltage	V_{RWM}	Crest working reverse voltage
V_{FSM}	Surge forward voltage, non-repetitive	V_S	Supply voltage
V_{FRM}	Repetitive peak forward voltage	V_T	Temperature voltage
V_{FWM}	Crest working forward voltage	V_Z	Z-operating voltage
V_{HF}	RF voltage, RMS value	Z_{thp}	Thermal resistance – pulse operation
V_{HF}	RF voltage, peak value	φ	Angle of current flow
V_R	Reverse voltage	η_r	Rectification efficiency
V_R	Reverse voltage, instantaneous total value	T_o	Time constant
V_{RSM}	Surge reverse voltage, non-repetitive	ΔC_D	Capacitance deviation